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PHOTOELECTRONIC PROPERTIES OF TERNARY NIOBIUM OXIDES.(U)  
SEP 80 K DWIGHT, A WOLD  
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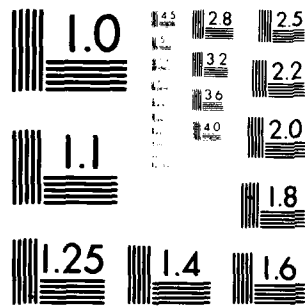
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ABSTRACT (Continue on reverse side if necessary and identify by block number) A series of ternary niobium oxides were prepared and their photoelectronic properties evaluated. When two species of photoactive centers are simultaneously present, the higher flat-band potential appears to dominate. But it is evident that both species contribute their characteristic sets of inter-band transitions to the ensemble. In this respect, these oxide semiconductors behave differently than the conventional, broad-band semiconductors. It would appear that different photoactive centers remain at		

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## 20. Abstract (Continued)

least partially independent. Hence, for  $\text{FeNbO}_4$ , the data show all the characteristics of the  $(\text{NbO}_6)$  octahedra in addition to all the characteristics of the  $(\text{FeO}_6)$  centers.

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K. Dwight and A. Wold

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## TERNARY NIOBIUM OXIDES

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The ternary iron oxides, as exemplified by the iron-niobium system, offer an opportunity to obtain single-phase, conducting n-type iron oxides; in which the conductivity can be controlled by means of chemical substitution. At first glance,  $\text{FeNbO}_4$  and  $\text{FeNb}_2\text{O}_6$  might appear to be very different materials. Yet as  $\text{MM}'_2\text{O}_4$  and  $\text{MM}'_2\text{O}_6$  they merely represent superstructures of the basic  $\alpha\text{-PbO}_2$  structure obtained under the conditions of preparation (7). Consequently, they form a solid solution in which the two valence states of iron are uniformly distributed throughout a single homogeneous phase (8).

For materials with a single photoactive center, it is generally observed that the optical band gap and flat-band potential are interrelated, so that lower band gaps appear to be accompanied by more positive flat-band potentials (4,9). Nevertheless, the non-active A-site ions in such ternary compounds as  $\text{BaTiO}_3$ ,  $\text{SrTiO}_3$ ,  $\text{Ba}_{0.5}\text{Sr}_{0.5}\text{Nb}_{2.6}\text{O}_{10}$  and  $\text{Sr}_2\text{Nb}_{2.7}\text{O}_{10}$  do have a perturbing effect.

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(4, 7, 9, 10). Consequently, if multiple photoactive centers can maintain sufficiently independent existence in a single compound, it would be conceivable that significant deviations from the usual correlation of high flat-band potentials with low band-gap energies might occur.

#### Effects of Composition and Structure

Before proceeding to ternary oxides with multiple photoactive centers, the effects of composition and structure upon such photoelectronic properties as optical band gap and flat-band potential for a given active center should be considered. It will be seen that composition appears to primarily affect the flat-band potential, whereas the band gap is more sensitive to structure.

$\text{Sr}_2\text{Nb}_2\text{O}_7$  is a pyrochlore;  $\text{Ba}_{0.5}\text{Sr}_{0.5}\text{Nb}_2\text{O}_6$  is a defect perovskite. In both materials, the  $[\text{NbO}_6]$  octahedra are the only photoactive centers. As shown in Figure 1, the flat-band potential of the pyrochlore is more negative by 0.4 volts, and its band gap is correspondingly larger, as would be expected. But the respective roles of structure and composition cannot be deduced from this comparison alone.

$\text{BaTiO}_3$  and  $\text{SrTiO}_3$  are both perovskites and have nearly the same optical band gaps. Yet the flat-band potential of  $\text{SrTiO}_3$  is 0.6 volts more negative than for the barium analog, a difference comparable in magnitude to that noted above for the niobates. Furthermore, it can be seen from Figure 1 that the band gap in the rutile  $\text{TiO}_2$  is significantly lower than in these perovskite titanates.

Thus, the behavior in both the titanium and niobium systems is consistent with the hypothesis that the A-site cation is primarily responsible for variation in flat-band potential while the structure is primarily responsible for variation in optical band gap. Of course, it has been noted elsewhere that other properties such as the magnitude of the quantum efficiency also depend upon structure (10).

From Figure 1 it is evident that  $\text{Fe}_2\text{O}_3$ ,  $\text{FeNbO}_4$ , and  $\text{FeTiO}_3$  all have relatively positive flat-band potentials, which is presumably a characteristic of the iron. The band gap in the titanate appears to be associated with the  $[\text{TiO}_6]$  octahedra; that in the niobate appears to match ferric oxide within structural variability. From such a cursory analysis, there would appear to be no effect from the presence of a second photoactive center in these two materials.

However, the existence of such an effect can be demonstrated by the application of a recently proposed technique for the study of interband transitions having energies greater than the "optical" band gap (11). Standard procedures exist for the extraction of band-gap information from measurement of the optical absorption coefficient, which has been shown to be proportional to the quantum efficiency (photocurrent density divided by the incident

light flux) under conditions applicable to the materials considered here (11, 12). The photoelectrolysis experiment provides an effective sampling region much thinner than can be obtained by polishing crystals, thereby extending the range of measurement to much higher energies. Since this technique is not yet widely known, an outline of its principal features is presented in the following section.

#### Band-Gap Analysis

Under moderate irradiation, the reaction rate in a photoelectrolysis cell is limited by the arrival rate of holes at the anode surface (12), in which case the quantum efficiency  $\eta$  is given by:

$$\eta = 1 - [\exp(-\alpha W)] / (1 + \alpha L_p)$$

where  $\alpha$  is the optical absorption coefficient,  $L_p$  is the hole diffusion length, and  $W$  is the width of the depletion layer (12). Also,

$$W = [2\epsilon\epsilon_0 (V - V_{fb}) / eN_0]^{1/2}$$

and

$$L_p \leq [\epsilon\epsilon_0 (kT/e) / eN_0]^{1/2}$$

since the hole diffusion length is determined by bulk recombination in highly defective oxides (11, 12).

The dielectric constant  $\epsilon$  can be estimated to be of the order of 100, and the donor concentration  $N_0$  can be estimated from the measured conductivity, activation energy and Hall mobility to be of the order of  $10^{20} \text{ cm}^{-3}$ . Then  $W \approx 10^{-6} \text{ cm}$  and  $L_p$  is even smaller, so that expansion of the exponential yields a quantum efficiency proportional to the optical absorption coefficient even for large values of  $\alpha$ .

The optical absorption coefficient for a single interband transition is related to the photon energy by  $\alpha \sim (h\nu)^{-1} (h\nu - E_g)^n$  where  $E_g$  is the band gap and  $n$  depends upon the character of the transition ( $n = 0.5$  for allowed direct transitions;  $n = 2$  for allowed indirect ones). Thus, if experimental values for  $\alpha$  are multiplied by  $h\nu$  and are plotted as  $(\alpha h\nu)^{1/n}$  against  $h\nu$ , then a straight line intersecting the energy axis at  $E_g$  will be obtained when  $n$  correctly characterizes the transition. Since the total optical absorption coefficient  $\alpha$  for a compound comprises the sum of such contributions from successive interband transitions, its complete analysis must proceed in stages. Each transition is characterized in turn, starting from the lowest energy, whereupon its contribution to the absorption is extrapolated to higher energies and subtracted from the total  $\alpha$ . However, the simple determination of the interband transition energies does not require this elaborate process, the onset of each additional contribution



to the total  $\alpha$  being clearly visible as an abrupt increase in the slope of the graph of  $(\alpha h\nu)^{1/n}$  vs  $h\nu$ . Furthermore, higher-energy direct transitions can often be identified unambiguously without subtracting the contributions from lower-energy indirect ones.

The absorption coefficient increases with increasing photon energy, and each successive transition adds to the rate of increase. Consequently, the analysis of higher-energy transitions is limited by the maximum value of  $\alpha$  which can be measured, which is inversely proportional to the thickness of the sample. In the photoelectrolysis experiment, the depletion layer forms a very narrow sampling region, so that the maximum value of  $\alpha$  measurable by  $\eta$  is large. This permits the determination of interband transitions well above the energy of the lowest band gap (11).

In order to illustrate the power and reliability of this analytical procedure, the quantum efficiency  $\eta$  measured for  $\text{SrTiO}_3$ , being proportional to  $\alpha$ , has been multiplied by the photon energy  $h\nu$  and is plotted in Figure 2 as  $(\eta h\nu)^{0.5}$  vs  $h\nu$ . The linearity of the lowest-energy section of this graph (with  $n = 2$ ) characterizes the transition as indirect. The energy intercept yields the value of 3.2 eV for the lowest band gap, which is in good agreement with previous absorption measurements (13) and with the calculation of Kahn and Leyendecker (14).

The abrupt increase in slope at 3.37 eV signals the presence of a higher-energy transition, in accord with the increased absorption found by electromodulation measurement (15). The decrease in slope at 3.5 eV corresponds to a saturation of this contribution to the total absorption and is not understood. Nevertheless, several other materials give evidence of similar behavior.

Finally, the transition at 3.74 eV agrees both with the electromodulation spectra (15) and with the band structure calculation (14). This higher-energy section does not appear greatly different from the rest of Figure 2, although there is some curvature of the data. However, this region becomes truly linear when replotted as  $(\eta h\nu)^2$  versus  $h\nu$ , which establishes the direct character of the high-energy transition.

### Results and Discussion

The quantum efficiency data for the defect pyrochlore  $\text{Ba}_{0.5}\text{Sr}_{0.5}\text{Nb}_2\text{O}_6$  is presented in Figure 3 (10). It shows an indirect band gap at 3.4 eV with a "tail" extending to nearly 2.6 eV. The higher-energy transition at 4.4 eV shows some curvature of the data, and indeed, corresponds to a direct transition when replotted as  $(\eta h\nu)^2$  versus energy (10).

Similar data for the pyrochlore  $\text{Sr}_2\text{Nb}_2\text{O}_7$  is plotted in Figure 4. Here the principle indirect band gap occurs at 3.9 eV with a "tail" to nearly 3.4 eV. The data beyond 4.3 eV cannot be interpreted quantitatively because of a breakdown in the conditions required for the band-gap analysis, but there is an indication of

a transition in the vicinity of 4.7 eV. Thus the behavior is qualitatively similar to that observed in the perovskite niobate, only shifted to higher energies.

The analogous results for the corundum  $\text{Fe}_2\text{O}_3$  are given in Figure 5. This shows an indirect band gap at 1.85 eV together with a direct band gap at 2.5 eV (11). Such simple behavior is in sharp contrast with the complex succession of transitions shown in Figure 6 for  $\text{FeNbO}_4$  (7). Here the lowest-energy transition at 2.05 eV is clearly indirect. It is followed by several higher-energy transitions at 2.68, 2.93, 3.24, and 4.38 eV, each giving rise to a sudden increase in the slope of the curve, but so close together as to preclude reliable determination of direct or indirect character.

The locations of these additional interband transitions are highly suggestive. That at 2.68 eV appears to correlate with the 2.58 eV transition for  $\text{Fe}_2\text{O}_3$  shown in Figure 5; those at 3.24, 2.9, and 4.38 eV are reminiscent of the indirect transition at 3.4 eV, its "tail," and the direct transition at 4.4 eV shown in Figure 3 for  $\text{Ba}_{0.5}\text{Sr}_{0.5}\text{Nb}_2\text{O}_6$ . Thus the data for  $\text{FeNbO}_4$  show all the characteristics of the  $[\text{NbO}_6]$  octahedra in addition to all the characteristics of the  $[\text{FeO}_6]$  centers. The greater similarity to the perovskite niobate can be attributed to closer agreement between their Nb-O bond strengths as compared with those in the pyrochlore structure.

#### Summary and Conclusions

When only a single species of photoactive center is present in a compound, the presence of a non-active, A-site cation produces a characteristic shift in the flat-band potential. A change in structure, however, will in general produce a shift in the optical band-gap energy. This is accompanied by corresponding shifts in any other, higher-energy interband transition, but the qualitative features remain the same, and hence appear to be characteristic of the particular photoactive center.

When two species of photoactive centers are simultaneously present, the higher flat-band potential appears to dominate. But it is evident that both species contribute their characteristic sets of interband transitions to the ensemble. In this respect, these oxide semiconductors behave differently than the conventional, broad-band semiconductors. It would appear that different photoactive centers remain at least partially independent.

However, further experimentation embracing a variety of ternary systems will be required to determine the degree of interaction between such multiple centers. Preliminary results for  $\text{Fe}_2\text{WO}_6$  confirm the superposition of two characteristic sets of interband transitions. The optical band gap and flat-band potential are essentially the same as in  $\text{FeNbO}_4$ , but the quantum efficiency is considerably greater. This suggests that there may be some enhancement of the photoresponse due to interaction between

the iron and tungsten centers.

#### Acknowledgements

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Figure Captions

Figure 1 - Optical band gaps and flat-band potentials (adjusted to pH = 13) for some photoanode materials (4, 7, 9, 10).

Figure 2 - Band-gap analysis for  $\text{SrTiO}_3$  (11), showing transitions at 3.2, 3.4, and 3.75 eV.

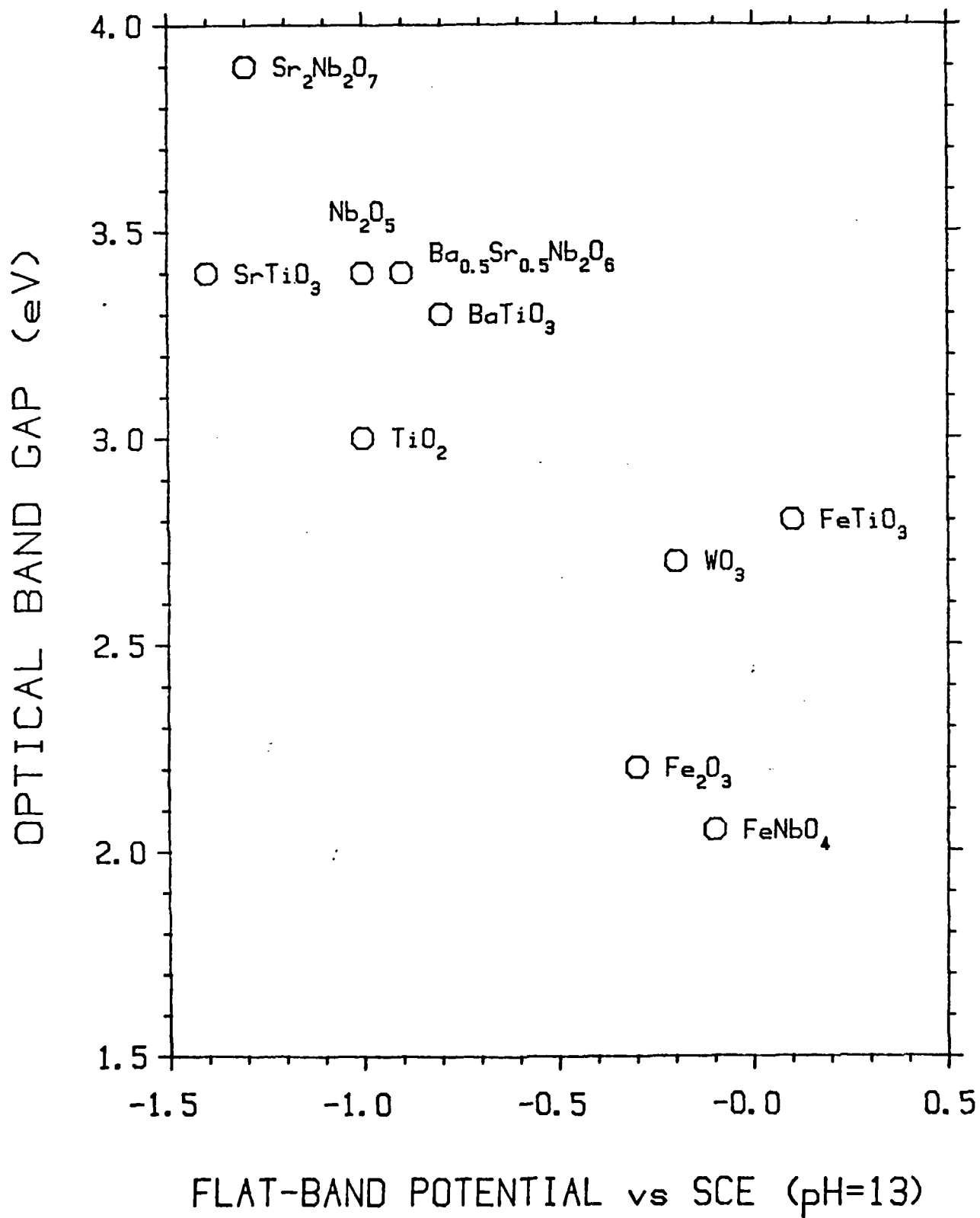
Figure 3 - Band-gap analysis for  $\text{Ba}_{0.5}\text{Sr}_{0.5}\text{Nb}_2\text{O}_6$  (10), showing transitions at 2.6, 3.4, and 4.4 eV.

Figure 4 - Band-gap analysis for  $\text{Sr}_2\text{Nb}_2\text{O}_7$  (10), showing transitions at 3.4 and 3.9 eV.

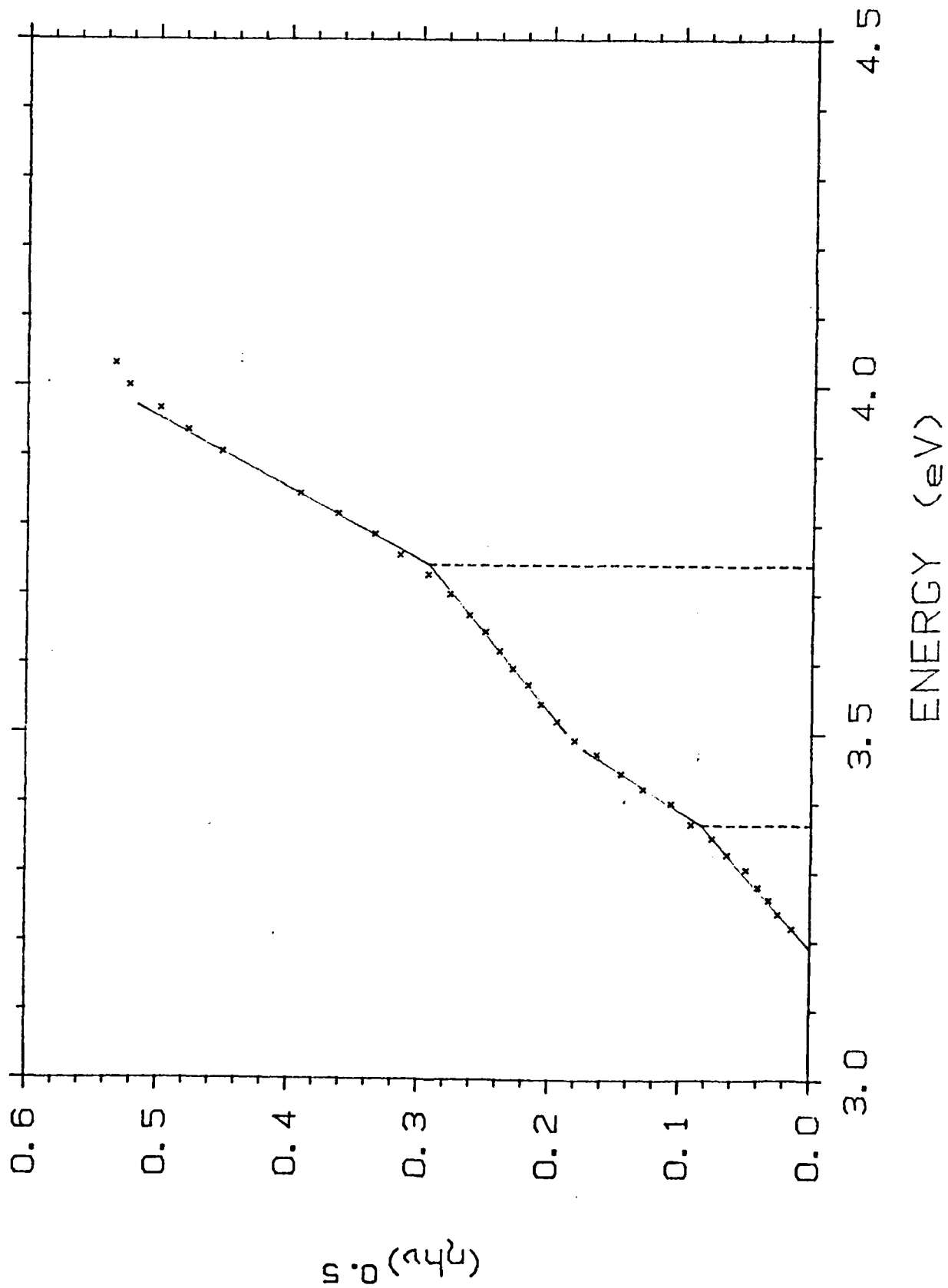
Figure 5 - Band-gap analysis for  $\text{Fe}_2\text{O}_3$  (11), showing transitions at 1.85 and 2.58 eV.

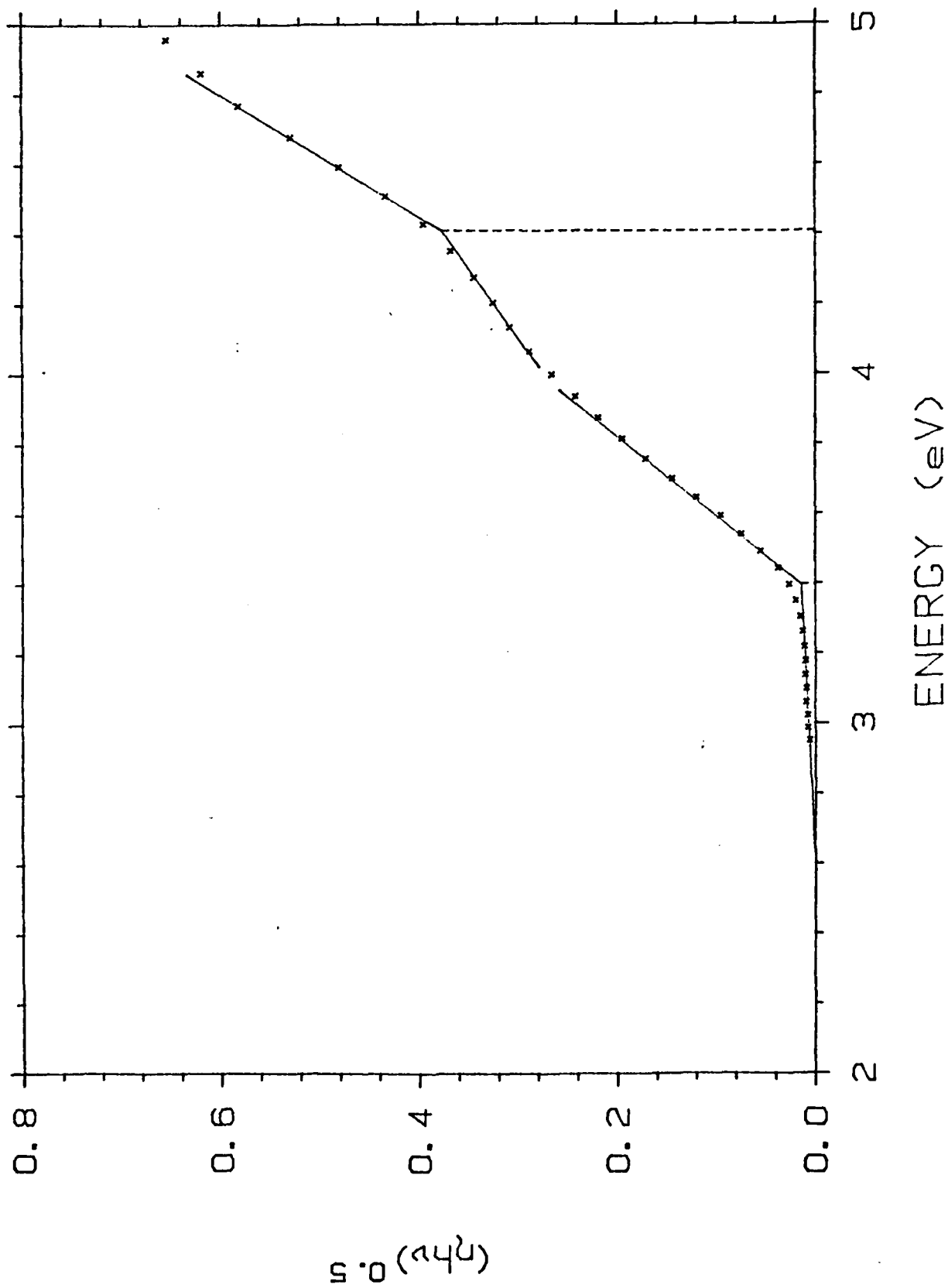
Figure 6 - Band-gap analysis for  $\text{FeNbO}_4$  (7), showing transitions at 2.05, 2.68, 2.9, 3.24, and 4.38 eV.

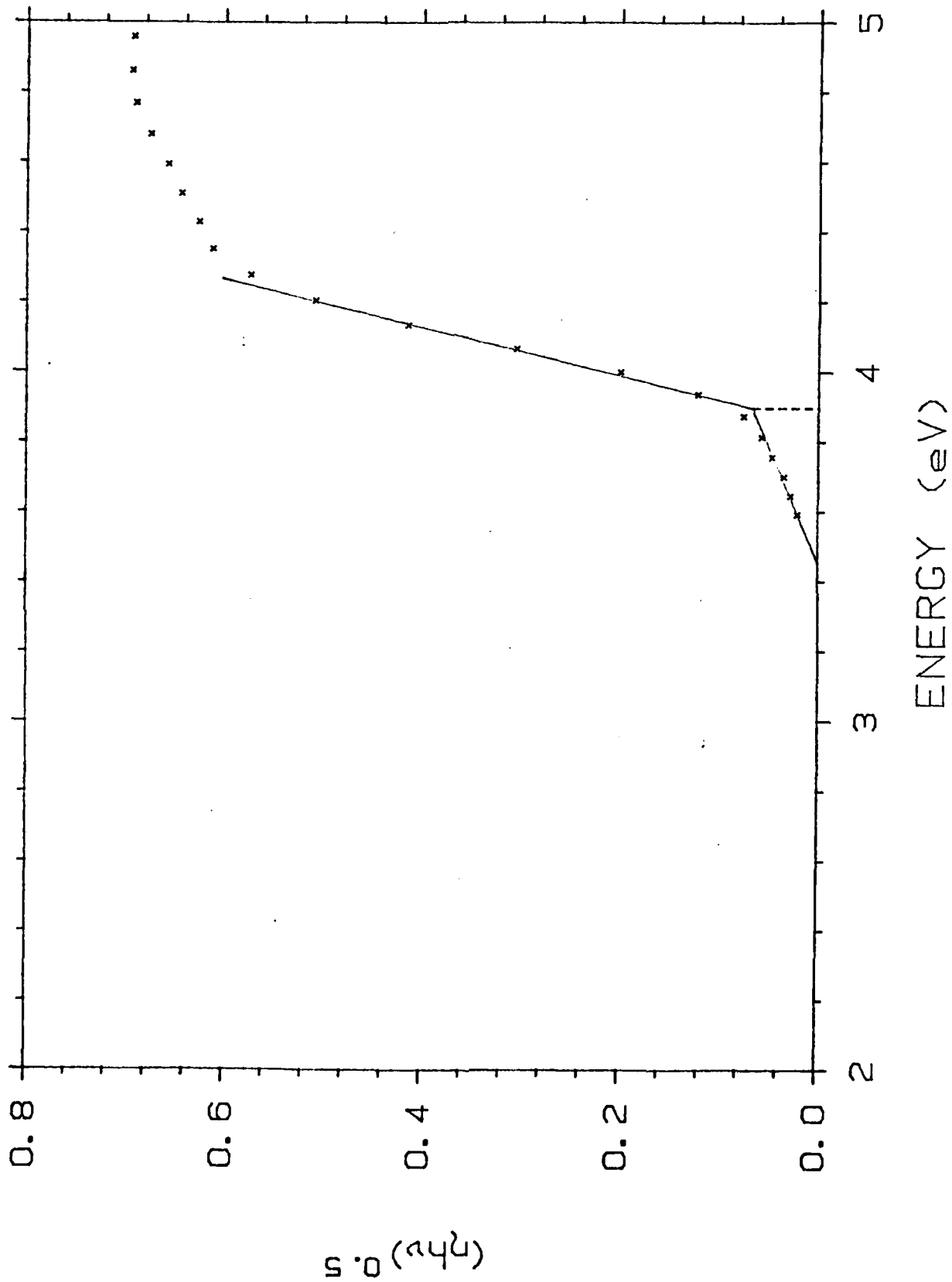
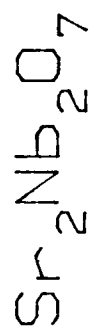
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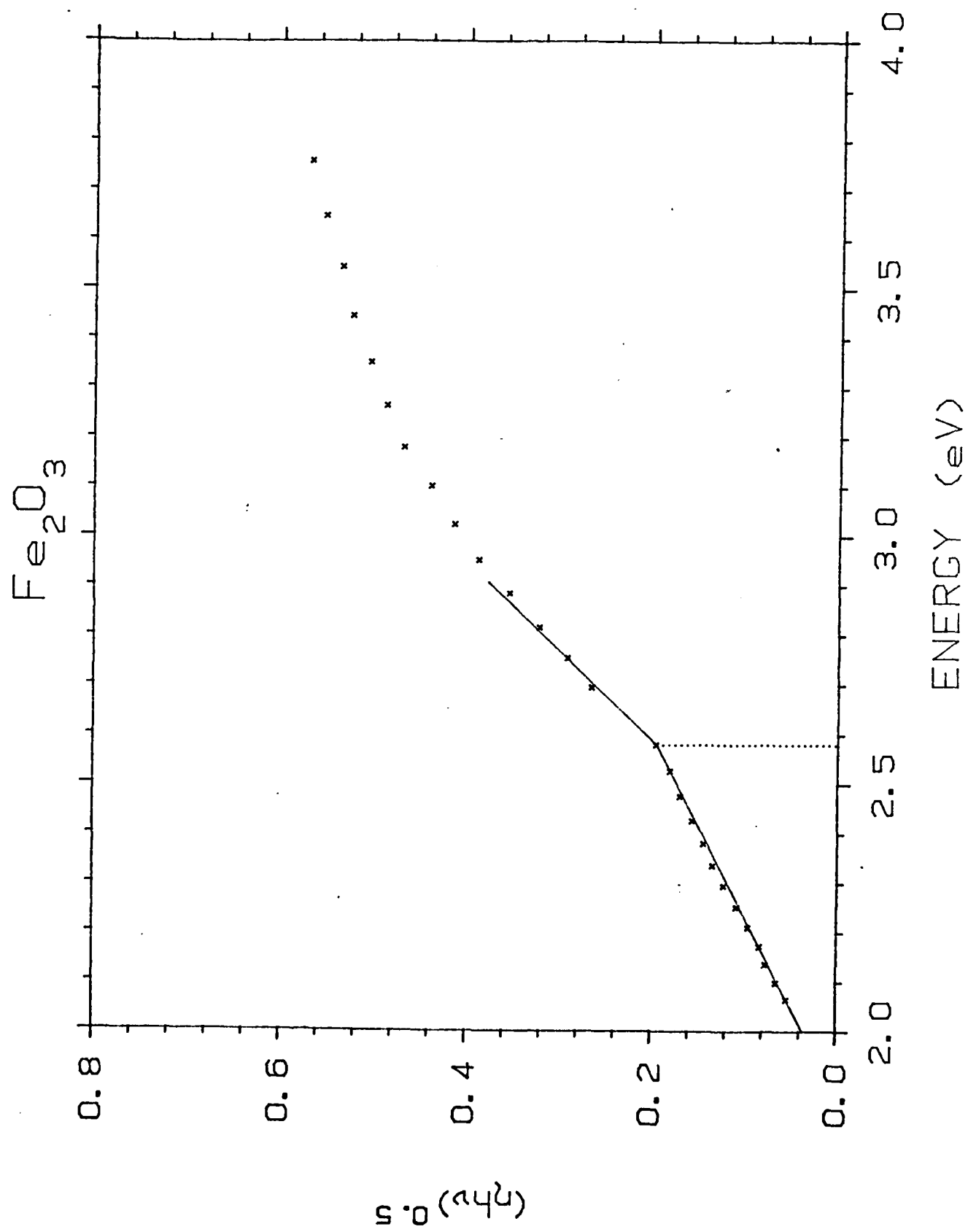
$\text{SrTiO}_3$



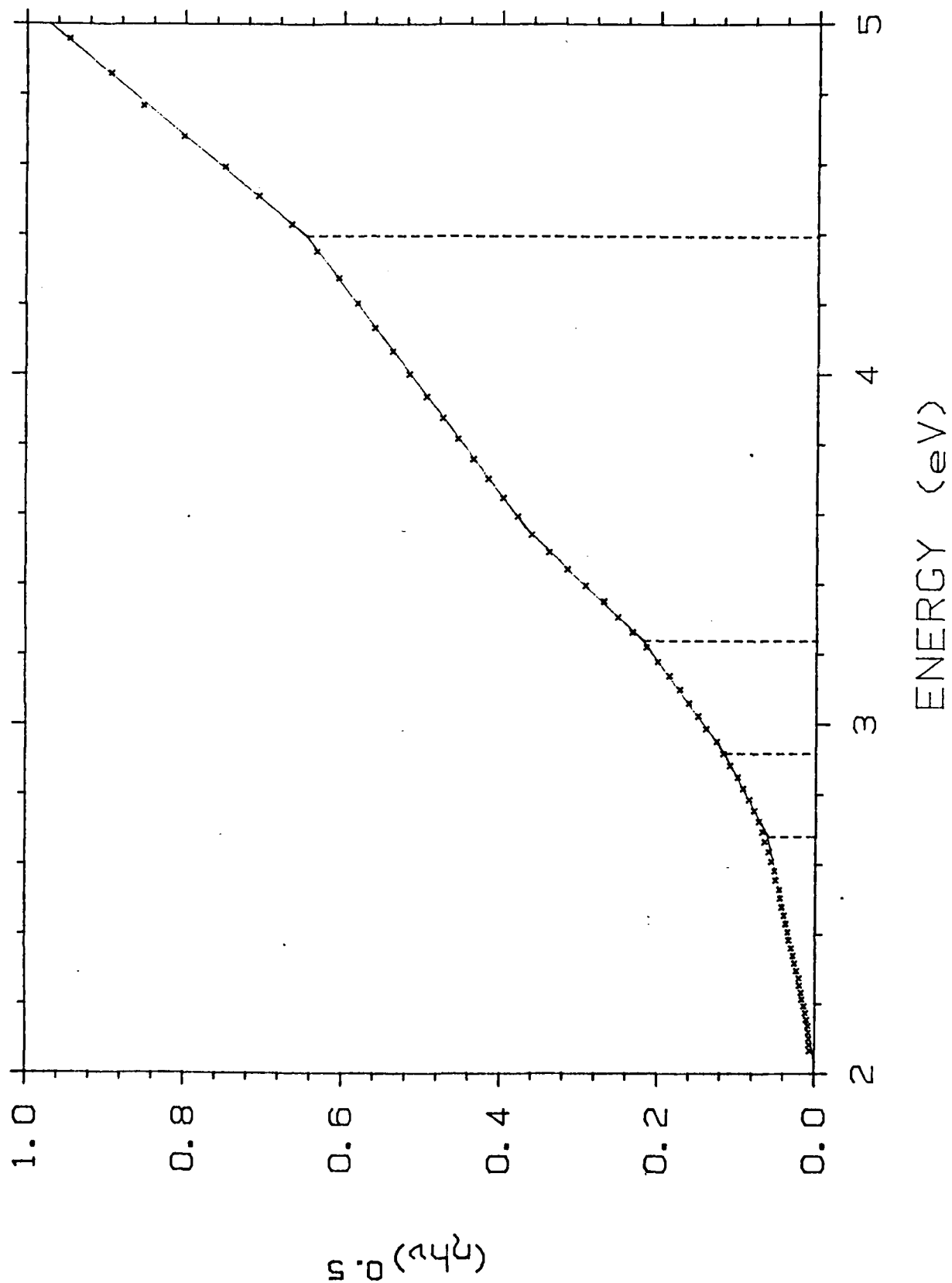








$\text{FeNbO}_4$



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